

# In situ grown epitaxial heterojunction exhibits high-performance electrocatalytic water splitting

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## Epitaxial Nanoconfinement Enhanced Electro-catalyst for Water Splitting

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Please submit a plain text version of your cover letter here.  <b>If you are submitting a revision of your manuscript, please do not overwrite your original cover letter. There is an opportunity for you to provide your responses to the reviewers later; please do not add them here.</b>	<p>Dear Editor,</p> <p>We are pleased to submit our new manuscript for publication consideration in Advanced Materials.</p> <p>In the energy community, people are developing non-precious metal electrocatalysts for HER/OER. It has been shown that multiple-element compounds and heterostructures generally show better performance than single oxides or carbides, because the interface electronic structure can be tailored. In this work, we present the epitaxial in-growth of Co@Ni<sub>3</sub>N nanoheterojunctions which are formed in-situ during nitridization of NiCo<sub>2</sub>O<sub>4</sub> nanowires. The obtained Co@Ni<sub>3</sub>N nanoheterojunctions show outstanding electro-catalytic performance in both HER and OER. First-principle calculations show both interfacial epitaxy and interface electron transfer. Therefore, we ascribe the good electrocatalytic performance to a “nanoconfinement effect”, a phenomenon proposed and evidenced by Prof Bao Xinhe in other catalyst systems.</p> <p>In addition to electrocatalytic performance, we also show in details the enhanced capacitive energy storage of the Co-Ni<sub>3</sub>N nanowires due to increased overall electric conductivity.</p> <p>The highlights of our work:</p> <ol style="list-style-type: none"><li>1.Co-Ni<sub>3</sub>N nanoheterojunctions with epitaxial interface formed in situ. During the transformation from oxides to nitrides, epitaxial heterojunctions due to phase decomposition, leading to two materials with intimate-contact and stable interface. We show this structure functions better than single-phase metal oxides or nitrides.</li><li>2.One unique structure, multiple enhancements. The epitaxial in-grown Co-Ni<sub>3</sub>N nanoarrays inherit functions of both Co and Ni<sub>3</sub>N and also induces catalytic property enhancement due to interface charge transfer, and capacitive enhancement due to increased conductivity. For example, lowered switch on voltages for both HER and OER, and higher turn off frequency (TOF); and evidently improved rate performance as the supercapacitor electrode.</li></ol> <p>Your consideration of this manuscript is highly appreciated.</p> <p>Sincerely,</p> <p>Hong Jin Fan School of Physical &amp; Mathematical Sciences Nanyang Technological University Email: fanhj@ntu.edu.sg</p>

Do you or any of your co-authors have a conflict of interest to declare?	No. The authors declare no conflict of interest.
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<b>Abstract:</b>	<p>It is technologically important to develop non-precious metal electrocatalysts for water electrolysis and fuel cells. It is known that the electro-catalytic performance can be significantly enhanced by interface engineering a purposely-designed nanoheterojunction structure, where the interface electronic structure can be fine-tuned. Herein, we have devised a new approach of developing atomic epitaxial in-growth in Co-Ni<sub>3</sub>N nanowires array, where a nanoconfinement effect is reinforced at the interface. We attest by first-principle calculations that the nanoconfinement effect facilitates electron transfer at the epitaxial interface, leading to a significant enhancement in catalytic activities for both hydrogen and oxygen evolution reactions (10 and 16 times higher in the respective turn-over frequency compared to Ni<sub>3</sub>N-alone nanorods). This nanoconfinement effect occurring during in-situ atomic epitaxial in-growth of two compatible materials provides a new and more effective pathway than the commonly-studied ternary metal oxides or nitrides towards high-performance electrocatalysis.</p>

# Epitaxial Nanoconfinement Enhanced Electro-catalyst for Water Splitting

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**Keywords:** Nanoconfinement; epitaxial in-growth; metal nitride nanoarrays; oxygen evolution reaction; hydrogen evolution reaction

1 In recent years, tremendous efforts are being paid to sourcing high performance electrode  
2 materials for both energy storage <sup>[1-3]</sup> and energy conversion via electro-catalysts water-  
3 splitting.<sup>[4]</sup> For these applications, the electrode materials shall be of high electrical  
4 conductivity, superior electrochemical activity and reliable long-term durability, as well as low-  
5 cost. State-of-art high-efficiency electrode materials are, for example, RuO<sub>2</sub> for both  
6 supercapacitor and oxygen evolution reaction,<sup>[5]</sup> Pt for Hydrogen evolution<sup>[6]</sup> and oxygen  
7 reduction reaction.<sup>[7, 8]</sup> However, more attentions lie in low-cost non noble metal electrode  
8 materials, which are transition metal oxides,<sup>[9]</sup> sulfides,<sup>[10]</sup> phosphides,<sup>[11]</sup> carbides,<sup>[12]</sup> and  
9 nitrides.<sup>[13]</sup> The electrocatalyst performance of these compounds largely depend on the  
10 structure features at varying scales. Nevertheless, their performances are still far from  
11 satisfaction, and there is considerable room for improvement by, for example, elemental doping,  
12 <sup>[14-16]</sup> construction of core-shell structures<sup>[14, 17]</sup> and epitaxial growth,<sup>[6, 7, 18-20]</sup> in addition to  
13 discovery of new catalyst systems. Taking Ni<sub>3</sub>N as an example, which is an intensively-studied  
14 electrocatalyst, Pt doping is shown to manifest capable of lowering the charge transfer  
15 resistance and thus improve the overall catalytic performance for HER.<sup>[21]</sup> In addition, a  
16 cheaper method of forming TiN@Ni<sub>3</sub>N core-shell structure also presents a high catalytic  
17 current.<sup>[17]</sup> However, it also comes with a high overpotential, which is ascribed to the  
18 undesirable interface between TiN and Ni<sub>3</sub>N, where a built-in electric field induces energy  
19 barrier for charge transfer. Among the attempts to enhance the electrocatalyst performance, an  
20 epitaxial growth with a lattice mismatch less than 5 % is preferable.<sup>[20]</sup> The epitaxial in-growth  
21 is generally advantageous in facilitating electron transfer between the two materials, and down-  
22 shifting the *d*-band center of metallic materials. However, conventional bottom-up epitaxial  
23 growths usually require a set of stringent processing conditions (as those in sputtering, thermal  
24 or e-beam lithography).<sup>13, 27</sup> In-situ epitaxial growth in a nanoscale without high temperature or  
25 vacuum may provide new opportunities.

51 The nano-confinement effect at the interface of two materials has been shown effective in  
52 reinforcing the co-existence of TiN and VN nanophases and the formation of Ti-V-N <sup>[22]</sup>  
53 epitaxial structure because of their lattice similarities. Inspired by this, we have sourced for the  
54 highly conductive candidates which share lattice similarities, and ideally can achieve synergy  
55 catalytic property. According to their crystal structures, Ni<sub>3</sub>N and metallic Co have good lattice  
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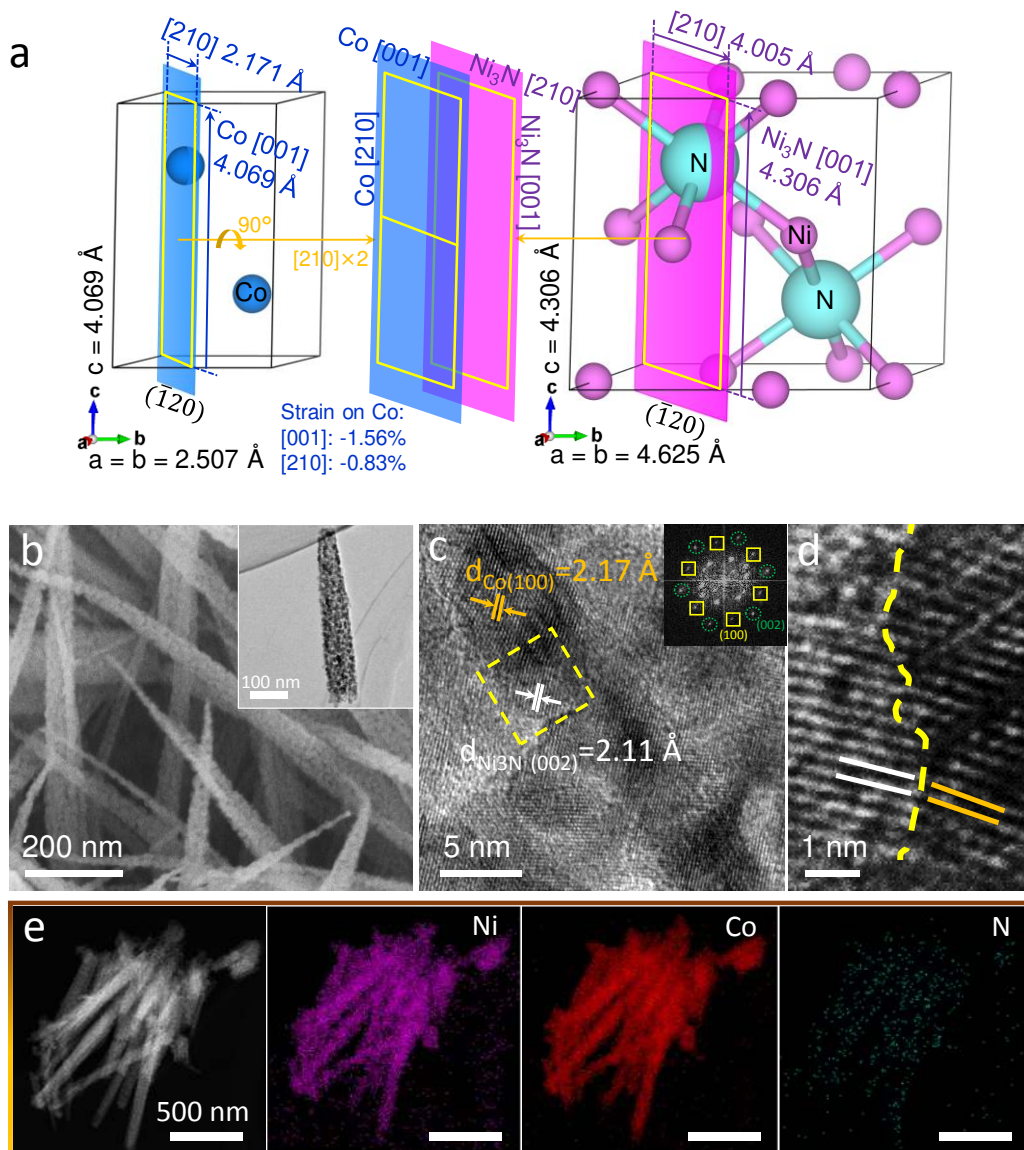
1 matching (e.g.,  $d_{\text{Ni}_3\text{N} (111)} \approx d_{\text{Co} (002)}$ ;  $d_{\text{Ni}_3\text{N} (002)} \approx d_{\text{Co} (100)}$  and  $d_{\text{Ni}_3\text{N} (302)} \approx d_{\text{Co} (103)}$ . Ni<sub>3</sub>N ref.  
2 JCPDS # 10-0280; Co ref. JCPDS # 89-4308). Thus, nanophased metallic Co and Ni<sub>3</sub>N can be  
3 in-grown in an integrated nanostructure, and generate synergy in addition to inheriting their  
4 individual functions.  
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8 We herein report the development of Co@Ni<sub>3</sub>N nanowires array with epitaxial in-grown  
9 internal structure, which are assembled on highly conductive carbon cloth. This nanowire  
10 arrays are thoroughly studied as electrocatalyst electrode for water splitting as well as  
11 supercapacitor. First-principle calculations not only supports the epitaxial interface but also  
12 implies efficient charge transfer across the Co@Ni<sub>3</sub>N interface. In consequence, the nano-  
13 confinement effect drastically enhances electrochemical activity of the Co@Ni<sub>3</sub>N epitaxial in-  
14 grown structure compared to the Ni<sub>3</sub>N-alone nanorods electrodes; the TOF values for HER and  
15 OER of the Co-Ni<sub>3</sub>N nanowires are 14.6 and 19.3 times larger than those of Ni<sub>3</sub>N electrode,  
16 respectively. Our results by both experiment and calculation provide strong evidence to the  
17 advantage of confinement effect induced reinforcement in nanostructured electrocatalysts,  
18 which might be a generic effect in many similar metal@metal nitrides or sulfide systems.  
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### 32 **Epitaxial in-growth and structure determination of Co-Ni<sub>3</sub>N nanorods**

33 The first-principles calculation suggests an epitaxial relationship between hexagonal cobalt  
34 metal (Co) and nickel nitride (Ni<sub>3</sub>N), as illustrated in **Figure 1a**. The ( $\bar{1}20$ ) planes of hcp Co  
35 and Ni<sub>3</sub>N in their unit cells are highlighted by the blue and pink planes respectively. The ( $\bar{1}20$ )  
36 plane of Co is defined by two orthogonal vectors of Co [210] and Co [001] with 2.171 and  
37 4.069 Å in length, respectively. Similarly, the ( $\bar{1}20$ ) plane of Ni<sub>3</sub>N is defined by two  
38 orthogonal vectors of Ni<sub>3</sub>N [210] and Ni<sub>3</sub>N [001] with 4.005 and 4.306 Å in length,  
39 respectively. The length of Co [001] (4.069 Å) is close to that of Ni<sub>3</sub>N [210] (4.005 Å) with  
40 only -1.56% in difference. Meanwhile, by doubling the length of Co [210] ( $2 \times 2.171 =$   
41  $4.342$  Å), Co [210] also matches well with that of Ni<sub>3</sub>N [001] (4.306 Å) with a small variation  
42 of -0.83%. Therefore, an epitaxial relationship exists between the ( $\bar{1}20$ ) planes of hcp Co and  
43 Ni<sub>3</sub>N by aligning Co [001] ([210]) with Ni<sub>3</sub>N [210] ([001]) and straining Co [001] and [210]  
44 by -1.56% and -0.83% respectively. By comparing three different “sewing” modes, we have  
45 determined the most stable N-Co interface at the edge (**Figure S1**). The detailed interface is  
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illustrated in **Figure S2** (see detailed discussion in Mechanism study section).

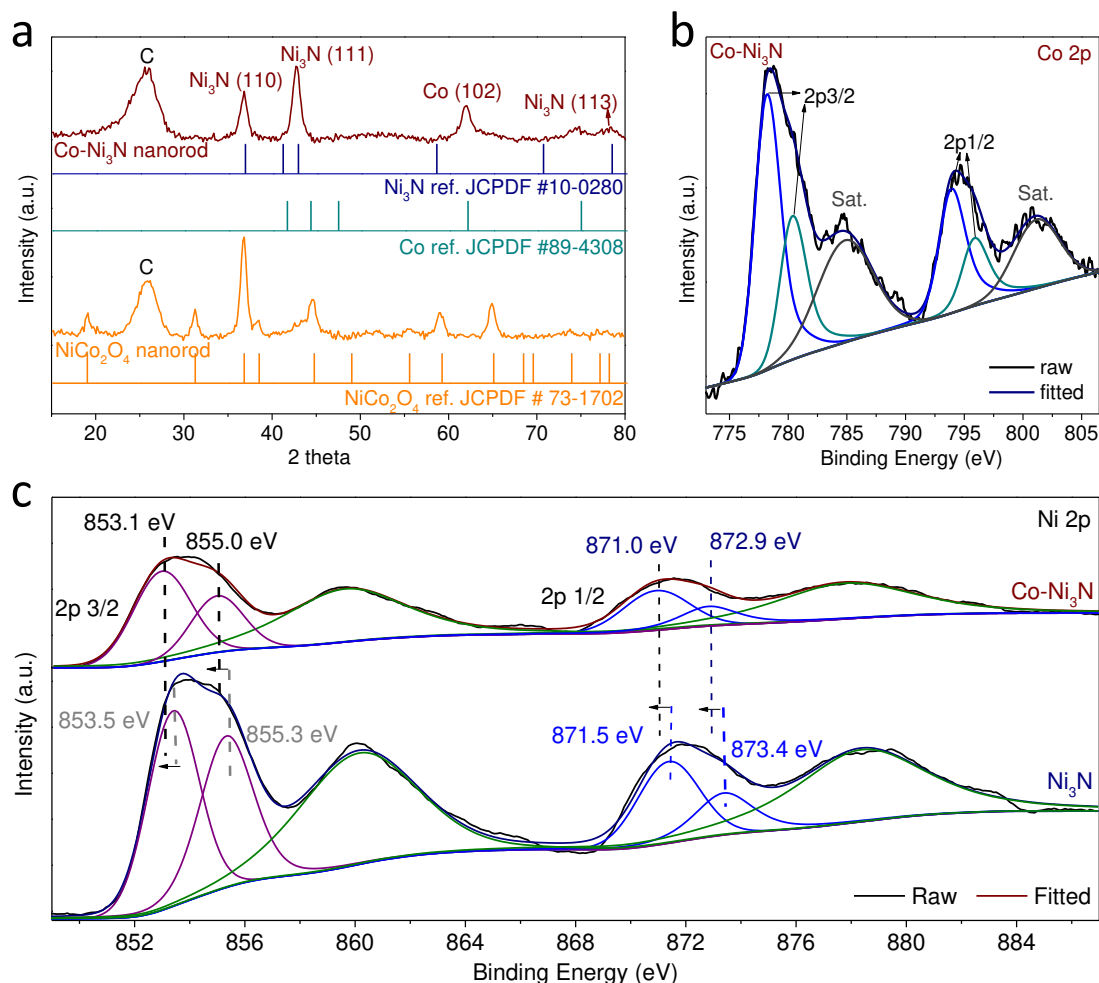


**Figure 1. Formation of Co-Ni<sub>3</sub>N nanorods with epitaxial in-growth structure.** a) Schematic illustration of lattice matching of metallic Co and Ni<sub>3</sub>N; SEM images of: b) the as-synthesized Co-Ni<sub>3</sub>N nanorods (inset is the low magnification TEM image of a single Co-Ni<sub>3</sub>N nanorod); c) and d) HRTEM images of Co-Ni<sub>3</sub>N nanorods (inset in c is the corresponding FFT image from the dashed box area). The dashed box indicates the co-existence of Co (100) and Ni<sub>3</sub>N (002) lattices, the dashed line indicates the interface between them; e) dark-field STEM image of Co-Ni<sub>3</sub>N nanorods, and the corresponding STEM elemental mappings of Ni, Co and N.

To develop the epitaxial in-growth within the nanorods, we choose a source material that contains both Co and Ni which is NiCo<sub>2</sub>O<sub>4</sub>. The fabrication process for Co-Ni<sub>3</sub>N nanorods

1 consists of two major steps, i.e. the hydrothermal growth of the source NiCo<sub>2</sub>O<sub>4</sub> nanorods array,  
2 and the ammonia annealing at a proper temperature (Detailed synthesis conditions are given in  
3 experimental part in supporting information). As shown by the scanning electron microscope  
4 (SEM) images (**Figure 1b**), the as-synthesized Co-Ni<sub>3</sub>N inherits the same morphology of the  
5 pristine NiCo<sub>2</sub>O<sub>4</sub> nanorod (**Figure S3b**). Moreover, as confirmed by TEM studies (**Figure 1b**  
6 and S3d), the Co-Ni<sub>3</sub>N nanoarrays (diameter ~ 80 nm, length ~ 1 μm) are composed of tiny  
7 nanoparticles, which gives rise to a large surface area that are beneficial to improving  
8 electrochemical activity. Similarly, the Ni<sub>3</sub>N nanophase (**Figure S4b**) maintains the  
9 morphology of its source NiO nanorod (**Figure S4a**). The lattices of both Ni<sub>3</sub>N and Co are  
10 visible in the high resolution TEM (HRTEM) images (**Figure 1c**). The Fast Fourier Transition  
11 (FFT) images (inset in **Figure 1c**) also reveals the lattice planes of Ni<sub>3</sub>N (002) and Co (100)  
12 pairs. Furthermore, there is clear demonstration for the coexistence of lattice fringes of metallic  
13 Co and Ni<sub>3</sub>N, which are explicitly discerned in **Figure 1d** with clear interface. In addition,  
14 there is lattice transfer from Co (100) (perpendicular to Co (210)) to Ni<sub>3</sub>N (002) (perpendicular  
15 to Ni<sub>3</sub>N (210)), which are ascribed to the nanoconfinement effect that restricts these two sets  
16 of lattice in a single unit cell. The confinement with epitaxial interface prevents detachment of  
17 the two materials at the nanoscale, which is in accordance with the first-principle calculation  
18 results. Elemental mappings of Ni, Co and N correspond well to those profiles of Co-Ni<sub>3</sub>N  
19 nanorods in **Figure 1e**.

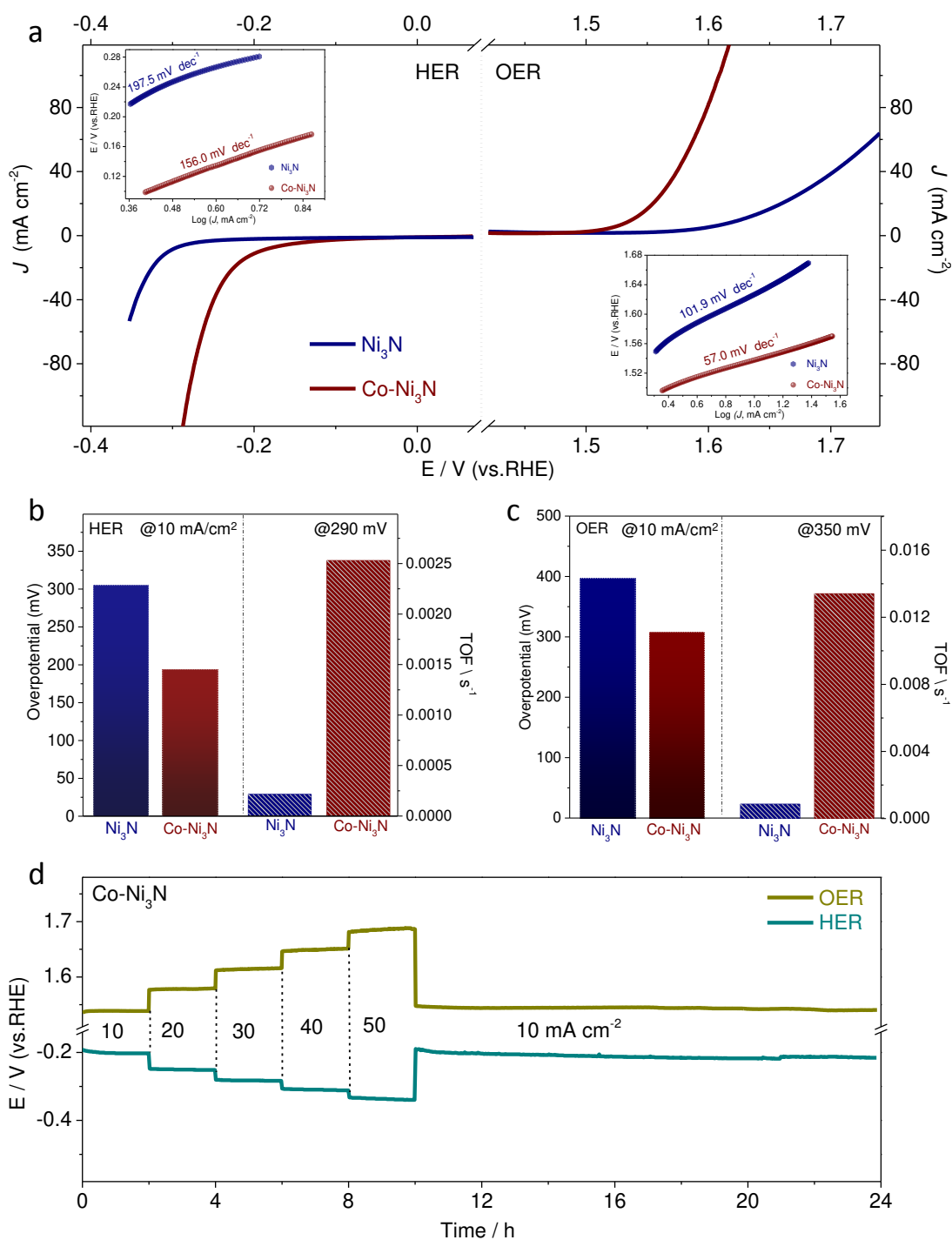




**Figure 2. Structure characterization of Co-Ni<sub>3</sub>N nanoarrays.** a) XRD spectra of Co-Ni<sub>3</sub>N and its source NiCo<sub>2</sub>O<sub>4</sub> nanorods showing the complete transformation after ammonia annealing treatment; XPS spectrum of: b) Co 2p in Co-Ni<sub>3</sub>N electrode, and c) Ni 2p signal comparison of Co-Ni<sub>3</sub>N and Ni<sub>3</sub>N electrode.

Further examination of the crystal structure of the Co-Ni<sub>3</sub>N nanoarrays are made by the X-ray diffraction (XRD). As shown in **Figure 2a**, the XRD spectrum of Co-Ni<sub>3</sub>N source material correspond well to the spinel NiCo<sub>2</sub>O<sub>4</sub> structure (Joint Committee on Powder Diffraction Standards, JCPDS card no.73-1702). After thermal annealing in ammonia, the typical peaks of Ni<sub>3</sub>N ((110) at  $2\theta = 38.9^\circ$ , (111) at  $2\theta = 44.4^\circ$ , (113) at  $2\theta = 78.4^\circ$ ) and metallic Co ((102) at  $2\theta = 62.4^\circ$ , (110) at  $2\theta = 75.9^\circ$ ) are observed, which are in agreement with JCPDS card no.10-0280 and 89-4308, respectively. In addition, X-ray photoelectron spectroscopy (XPS) was utilized to examine the sample surface. In the wide-scan range, sharp peaks of both N 1s and Ni 2p are detected in Co-Ni<sub>3</sub>N and Ni<sub>3</sub>N samples (**Figure S5b**). Analysis of XPS spectrum for Co 2p signal (**Figure 2b**) in Co-Ni<sub>3</sub>N nanorods indicates that Co is mainly at zero valence state

1 (located at 778.1 and 781.1 eV) which is consistency with XRD and HRTEM studies. The other  
2 two peaks (794.3 and 797.3 eV) can be indexed to CoO, which may well be due to the slight  
3 oxidization of the sample when exposed to air before measurement.<sup>[23,24]</sup> Meanwhile, two sharp  
4 peaks at around 853.1 and 871.0 eV (**Figure 2c**) belong to Ni 2p in Ni<sub>3</sub>N, where Ni is prone to  
5 be at its low valence state similarly to that of Ni in the Ni<sub>3</sub>N alone electrode.<sup>[25]</sup> The other two  
6 peaks at 855.0 and 872.9 eV may come from NiO resulted from partial oxidization of the Co-  
7 Ni<sub>3</sub>N sample surface<sup>[14, 26, 27]</sup> It is noted that, for an identical peak, the binding energy of Ni 2p  
8 is slightly lower in Co-Ni<sub>3</sub>N than that in Ni<sub>3</sub>N, indicating extra charges in the Ni side, which  
9 need further confirmation by bader charge calculation. The binding energy of N 1s in Co-Ni<sub>3</sub>N  
10 (**Figure S5c**) and Ni<sub>3</sub>N (**Figure S5d**) is 398 and 398.7 eV, respectively, which are the typical  
11 peaks of the metal nitride. The slightly lower (~ 0.7 eV) binding energy of N 1s in Co-Ni<sub>3</sub>N is  
12 also related to the charge accumulation in Ni<sub>3</sub>N. The atomic concentration ratio of Ni to N is  
13 calculated to be 2.9:1, by integrating the peak areas with their sensitivity factors (N: 0.38; Ni:  
14 5.4). Furthermore, the Raman shift peaks in Co-Ni<sub>3</sub>N and Ni<sub>3</sub>N are located in the similar  
15 position of ~ 460 cm<sup>-1</sup> (**Figure S5a**), which is in accordance with the stretching mode of Ni-N  
16 bond.  
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**Figure 3. Electro-catalytic performance.** a) LSV curves for the Co-Ni<sub>3</sub>N and Ni<sub>3</sub>N nanorod arrays for both hydrogen evolution reaction and oxygen evolution reaction catalyst (insets are the related Tafel plots for each application); b) Comparison of overpotentials of Ni<sub>3</sub>N and Co-Ni<sub>3</sub>N electrodes for HER at the current density of 10 mA cm<sup>-2</sup> (left panel) and the corresponding TOF values at an overpotential of 290 mV (right panel). c) Comparison of overpotentials of Ni<sub>3</sub>N and Co-Ni<sub>3</sub>N electrodes for OER at the current density of 10 mA cm<sup>-2</sup> (left panel) and the corresponding TOF values at an overpotential of 350 mV (right panel); d) stability tests of Co-Ni<sub>3</sub>N at varied current densities for both HER and OER processes.

## Electro-catalytic performance

In order to figure out the effect of nanoconfinement of Co-Ni<sub>3</sub>N on catalytic performance, its electro-catalytic activity was investigated in N<sub>2</sub> saturated 1.0 M KOH solution using the typical three-electrode setup by linear sweep voltammetry (LSV) with Ni<sub>3</sub>N as a comparison. Overall, the IR-corrected polarization curves for all samples (**Figure 3a**) clearly show that the Co-Ni<sub>3</sub>N electrode owns better catalytic activity than that of Ni<sub>3</sub>N for both hydrogen and oxygen evolution reaction (HER and OER). Specifically, for HER, the overpotential of Co-Ni<sub>3</sub>N at 10 mA cm<sup>-2</sup> (194 mV) is ~ 100 mV smaller than that of Ni<sub>3</sub>N (305 mV). Meanwhile, at the overpotential of 290 mV, the current density of Co-Ni<sub>3</sub>N is 14.6 times larger than that of Ni<sub>3</sub>N (48.325 versus 3.318 mA cm<sup>-2</sup>). The turnover frequency (TOF) value (**Figure 3b**) was calculated, based on the assumption that all metals in the catalysts were involved into the HER catalytic reaction. Clearly, Co-Ni<sub>3</sub>N presents much higher turnover frequency with a TOF value of 0.1459 s<sup>-1</sup> at the overpotential of 290 mV, which is 10 times of that for Ni<sub>3</sub>N nanoarrays (0.0142 s<sup>-1</sup>). The linear portions of Tafel plots were fit to Tafel equation ( $\eta = a + b \log j$ , where  $j$  is the current density and  $b$  is Tafel slope), yielding a Tafel slope of ~ 156.0 mV dec<sup>-1</sup> for Co-Ni<sub>3</sub>N (**Figure 3a**, upper left), which is lower than that of Ni<sub>3</sub>N (197.5 mV dec<sup>-1</sup>). The better conductivity of Co-Ni<sub>3</sub>N nanoarrays, compared to that of Ni<sub>3</sub>N, shall have contributed to the superior electro-catalytic performance. This is confirmed by the electrochemical impedance spectroscopy (EIS) study (**Figure 6b**), where Co-Ni<sub>3</sub>N owns a low charge transfer resistance (~ 20 Ω), 10 times lower than that of Ni<sub>3</sub>N electrode (~ 200 Ω).

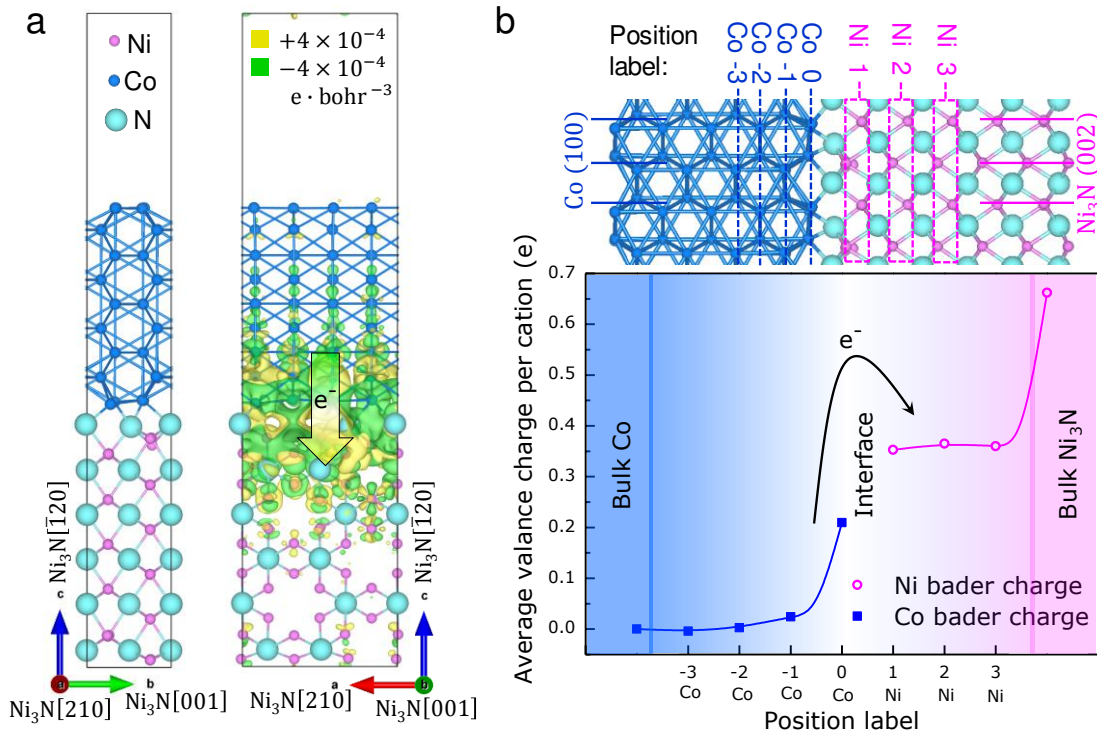
For OER application, Co-Ni<sub>3</sub>N needs 1.537 V (overpotential: 307 mV) to deliver a current density of 10 mA cm<sup>-2</sup>, while Ni<sub>3</sub>N requires a much larger overpotential of 1.627 V. The current density (127.87 versus 6.63 mA cm<sup>-2</sup>) and TOF value of Co-Ni<sub>3</sub>N (0.0134 s<sup>-1</sup>) at the overpotential of 350 mV are 19.3 times and 15.8 times larger than that of Ni<sub>3</sub>N (0.00086 s<sup>-1</sup>), respectively. Moreover, the Tafel slope of Co-Ni<sub>3</sub>N is 57.0 mV dec<sup>-1</sup>, which is much smaller than that of Ni<sub>3</sub>N (~ 101.9 mV dec<sup>-1</sup>). Therefore, the Co-Ni<sub>3</sub>N affords a larger current density and larger TOF value at lower overpotential, attributing to its unique epitaxial in-grown structure in the nanoarrays. In terms of the electrochemical conductivity, a smaller charge transfer resistance (2Ω) is observed for Co-Ni<sub>3</sub>N than that of Ni<sub>3</sub>N (9Ω) (**Figure S6d**), suggesting a much faster electron transfer during the electrochemical reaction, arising from the

1 existence of metallic Co nanophase in Co-Ni<sub>3</sub>N.

2 To figure out the endurance of the electrodes towards repeating electro-catalytic processes,  
3 we applied a variety of current densities (10, 20, 30, 40 and 50 mA cm<sup>-2</sup>) sequentially for 10 h  
4 on the Co-Ni<sub>3</sub>N electrode both for HER and OER (**Figure 3d**). In overall, the overpotential to  
5 deliver certain current density remains almost unchangeable, which indicates the excellent  
6 stability of Co-Ni<sub>3</sub>N, due to the high integrity of the nanostructure. In particular, when the  
7 current density is reverted to 10 mA cm<sup>-2</sup> after undergoing high current density flow, the voltage  
8 rapidly resumes and prevails over an additional prolonged 20 h test. The overpotential values  
9 for both HER and OER are mostly recovered, when switched back to 10 mA cm<sup>-2</sup>. This  
10 demonstrates the stability and durability of the Co-Ni<sub>3</sub>N nanostructure, capable of sustaining  
11 high current flow and fast electron movement. Furthermore, when extend the test to 20 hours,  
12 the Co-Ni<sub>3</sub>N nanoarrays remains a better durability with a lower stable overpotential than that  
13 of Ni<sub>3</sub>N electrode both for HER (**Figure S6a**) and OER (**Figure S6c**). It should be noted that,  
14 while our XPS study of the electrode after the OER test did not indicate oxidation of Ni<sub>3</sub>N, the  
15 possibility of slight surface oxidation should not be ruled out, which has been commonly  
16 observed in a few nanostructured metal nitride based OER electrode.

### 35 Mechanism Study

36 Comprehensive first-principles calculations are performed to investigate the stability and  
37 charge transfer at the Co/Ni<sub>3</sub>N ( $\bar{1}20$ ) interface. First of all, different Co/Ni<sub>3</sub>N ( $\bar{1}20$ )  
38 interface structures, including N-Co-interface, Ni1-Co-interface and Ni2-Co-interface (see  
39 **Figure S1** and **S2**), are constructed, and attempted by aligning Co [001] ([210]) with Ni<sub>3</sub>N [210]  
40 ([001]) and straining Co [001] and [210] by -1.56% and -0.83%, respectively. Therein, the N-  
41 Co-interface is found to be the most stable due to a small interfacial energy of -181~-178  
42 meV/Å<sup>2</sup> (**Figure S1**). The negative value means that the N-Co-interface will readily form when  
43 combining hcp Co and Ni<sub>3</sub>N during synthesis. This is possible because the N-terminated plane  
44 of Ni<sub>3</sub>N and Co-terminated plane of Co form stable N-Co bonds as in CoN. Furthermore, the  
45 b-c plane of the N-Co-interface model in **Figure 1a** left and **Figure 1b** up can be indexed to  
46 the Co (100) plane and Ni<sub>3</sub>N (002) plane, which are also observed in the TEM observation.  
47 It suggests that the *N-Co-interface model* supports our experimental observation.



**Figure 4. First-Principles calculations to illustrate interface charge transfer.** a) Structures of the N-Co interface formed between hcp Co and Ni<sub>3</sub>N by joining N-terminated ( $\bar{1}\bar{1}20$ ) slab of Ni<sub>3</sub>N and Co-terminated ( $\bar{1}\bar{1}20$ ) slab of hcp Co. Charge density difference due to the formation of interface is displayed on the right, where the yellow and cyan represent electron accumulation ( $\Delta\rho = +6 \times 10^{-4} e \cdot \text{bohr}^{-3}$ ) and depletion ( $\Delta\rho = -6 \times 10^{-4} e \cdot \text{bohr}^{-3}$ ), respectively; b) Bader charge analysis of Co and Ni cations near the N-Co interface and in bulk Co and Ni<sub>3</sub>N, respectively.

Interface charge transfer enhances the electro-catalytic activity for HER. The charge density difference in **Figure 4a** right illustrates that electrons transfer from Co to Ni<sub>3</sub>N, where Ni and Co cations near the interface gain and loss electrons respectively. Moreover, bader charge analysis is performed on the Ni and Co cations at the N-Co interface and bulk models, as seen in **Figure 4b**. The average valence charge of Co increases with decreasing distance to the interface. On the contrary, the average valence charge of Ni decreases with decreasing distance to the interface. It affirms that electrons transfer from the Co to Ni cations near the interface, which can be due to the interfacial Co 3d-N 2p-Ni 3d hybridizations (**Figure S8**). It has been reported that the active HER site in Ni<sub>3</sub>N is on Ni cations with a positive free energy change.<sup>[21]</sup>

1 28-31] Therefore, the rate limiting step for the HER process is the unstable absorption of H  
2 adatom on Ni. [32] By transferring electrons from Co to Ni near the N-Co-interface, [40] [33] the  
3 additional electrons on Ni will stabilize the H adatom and hence benefit the HER catalytic  
4 activity. [34-37]  
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9 It is reported that the active HER site in Ni<sub>3</sub>N is on 3-fold Ni hollow site having a positive  
10 free energy change  $G_{H^*}$ . [32] The positive  $G_{H^*}$  reveals that the rate limiting step for HER process  
11 on Ni<sub>3</sub>N is the unstable adsorption of H adatom. **Figure S9** shows the calculated HER free  
12 energy diagrams for various Ni hollows sites near the N-Co-interface. The  $G_{H^*}$  decreases from  
13 ~0.10 eV (position 3) to ~0.04 eV (position 1) with decreasing distance between the HER site  
14 and the N-Co-interface. It shows that the Ni hollow site close to the interface has superior HER  
15 activity compared to those farther away from the interface. This is in consistent with our  
16 interface charge transfer argument; Electrons transfer from Co to Ni near the N-Co-interface  
17 and the additional electrons on Ni can stabilize the H adatom giving rise to a much reduced  
18  $G_{H^*}$ . Therefore, our first-principles calculations unveil that the epitaxial interface between Ni<sub>3</sub>N  
19 and Co enhances the HER activity of Ni<sub>3</sub>N by inducing electron transfer from Co to Ni.  
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31 Furthermore, nanostructured metal nitrides are also commonly investigated for  
32 supercapacitor applications, in which reversible surface redox reactions give rise to fast charge  
33 storage/release performance. We also employed the Co-Ni<sub>3</sub>N nanorods as pseudocapacitive  
34 cathode and compared to the pure Ni<sub>3</sub>N (see **Figure S10 and S11** for detailed characterization and  
35 related discussion in Supporting Information). It is found that, compared to the pure Ni<sub>3</sub>N nanorods  
36 electrode, the Co-Ni<sub>3</sub>N nanorods array has a more capacitive behavior and better tolerance to  
37 high scan speeds. This difference can also be attributed to the better conductivity and  
38 electrochemical stability of the Co-Ni<sub>3</sub>N nanorods, in consistence with the above result.  
39 Interestingly, the quasi-rectangular CV loops with absence of evident redox peaks may imply that  
40 the Co or Ni<sub>3</sub>N are not seriously oxidized (despite unavoidable surface partial oxidation) during the  
41 measurements.  
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54 To wrap up, in connection with discussions above, four points are worth highlighting of the  
55 Co-Ni<sub>3</sub>N nanoarrays electrode synthesized in the present study: *firstly*, the combination of the  
56 two structurally matching materials of Co and Ni<sub>3</sub>N with similar lattice parameters can inherit  
57 the characteristics of both nanophases, i.e., Co-Ni<sub>3</sub>N combines the high activity for Herovskyy  
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1 and Tafel steps and can quickly desorb the  $\text{OH}^-$  during the reactions. *Secondly*, the introduction  
2 of the metallic Co nanophase efficiently enhances the overall electrical conductivity, which is  
3 key to both the fast charge transports in the HER/OER processes and the capacitive process in  
4 pseudocapacitive charge storage. *Thirdly*, the epitaxial in-grown interface between Co and  
5  $\text{Ni}_3\text{N}$  facilitates electron transfer between the two phases (from Co to Ni), which will stabilize  
6 the H adatom and lower the HER free energy thus benefiting the HER catalytic activity. *Finally*,  
7 the nanorod structure not only increases the surface areas compared to films, but also facilitate  
8 quasi-one-dimensional charge transport along the nanorods, leading to excellent  
9 electrochemical activity.

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11 In conclusion, we have developed a well-configured nanoarrays structure for Co- $\text{Ni}_3\text{N}$ ,  
12 derived from the corresponding oxide precursor, where epitaxial in-growth of the two  
13 structurally matching nanophase takes place, giving rise to unique nanoconfinement at the  
14 interface. The Co- $\text{Ni}_3\text{N}$  nanoarrays thus-derived inherit the functions of both Co and  $\text{Ni}_3\text{N}$ ,  
15 together with the refined structural features and epitaxial interface, leading to high performance  
16 for hydrogen and oxygen evolution reactions, with a lower switch on potential, faster turn over  
17 speed and better long-term durability being observed. Furthermore, when employed as a  
18 supercapacitor cathode, the Co- $\text{Ni}_3\text{N}$  nanoarrays demonstrate the dominating capacitive  
19 process, giving rise to high-rate charge storage performance. This work demonstrates a new  
20 pathway for developing nanostructured electrode materials, where the two structurally  
21 matching nanophases are synergized by an epitaxial in-grown interface leading to much  
22 enhanced electrocatalytic performance.

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## 29 **Reference**



- 1 [1] M.-S. Balogun, Y. Huang, W. Qiu, H. Yang, H. Ji, Y. Tong, *Mater. Today* **2017**.
- 2 [2] N. Choudhary, C. Li, J. Moore, N. Nagaiah, L. Zhai, Y. Jung, J. Thomas, *Adv. Mater.* **2017**, 1605336.
- 3 [3] G. Wang, L. Zhang, J. Zhang, *Chem Soc Rev* **2012**, *41*, 797.
- 4 [4] S. J. C. Robinson, D. M. Heinekey, *Chem. Commun.* **2017**.
- 5 [5] J. Xu, Q. Wang, X. Wang, Q. Xiang, B. Liang, D. Chen, G. Shen, *ACS Nano* **2013**, *7*, 5453.
- 6 [6] T. Bian, H. Zhang, Y. Jiang, C. Jin, J. Wu, H. Yang, D. Yang, *Nano Lett.* **2015**, *15*, 7808.
- 7 [7] C. Meng, T. Ling, T.-Y. Ma, H. Wang, Z. Hu, Y. Zhou, J. Mao, X.-W. Du, M. Jaroniec, S.-Z. Qiao, *Adv. Mater.* **2017**,
- 8 *29*, 1604607.
- 9 [8] J. Li, H.-M. Yin, X.-B. Li, E. Okunishi, Y.-L. Shen, J. He, Z.-K. Tang, W.-X. Wang, E. Yücelen, C. Li, Y. Gong, L. Gu,
- 10 S. Miao, L.-M. Liu, J. Luo, Y. Ding, **2017**, *2*, 17111.
- 11 [9] H. Jiang, J. Ma, C. Li, *Adv. Mater.* **2012**, *24*, 4197.
- 12 [10] Q. Lu, Y. Yu, Q. Ma, B. Chen, H. Zhang, *Adv. Mater.* **2016**, *28*, 1917.
- 13 [11] Y. Shi, B. Zhang, *Chem. Soc. Rev.* **2016**, *45*, 1529.
- 14 [12] Y. Zhong, X. Xia, F. Shi, J. Zhan, J. Tu, H. J. Fan, *Advanced Science* **2016**, *3*.
- 15 [13] S. Dong, X. Chen, X. Zhang, G. Cui, *Coord. Chem. Rev.* **2013**, *257*, 1946.
- 16 [14] B. Zhang, C. Xiao, S. Xie, J. Liang, X. Chen, Y. Tang, *Chem. Mater* **2016**, *28*, 6934.
- 17 [15] M. Chen, Y.-J. Zhao, J.-H. Liao, X.-B. Yang, *Phys. Rev. B* **2012**, *86*, 045459.
- 18 [16] J. Luo, Z.-J. Cui, G.-L. Zang, *Journal of Chemistry* **2013**, *2013*.
- 19 [17] Q. Zhang, Y. Wang, Y. Wang, A. M. Al-Enizi, A. A. Elzatahry, G. Zheng, *J. Mater. Chem. A* **2016**, *4*, 5713.
- 20 [18] C. Hahn, T. Hatsukade, Y.-G. Kim, A. Vailionis, J. H. Baricuatro, D. C. Higgins, S. A. Nitopi, M. P. Soriaga, T. F.
- 21 Jaramillo, *Proc. Natl. Acad. Sci.* **2017**, *114*, 5918.
- 22 [19] W. Wang, J. Goebel, L. He, S. Aloni, Y. Hu, L. Zhen, Y. Yin, *J. Am. Chem. Soc.* **2010**, *132*, 17316.
- 23 [20] X. Huang, Z. Zeng, S. Bao, M. Wang, X. Qi, Z. Fan, H. Zhang, *Nat. Commun.* **2013**, *4*, 1444.
- 24 [21] Y. Wang, L. Chen, X. Yu, Y. Wang, G. Zheng, *Adv. Energy Mater.* **2017**, *7*, 1601390.
- 25 [22] A. Fischer, J. O. Müller, M. Antonietti, A. Thomas, *ACS Nano* **2008**, *2*, 2489.
- 26 [23] M. Yu, Z. Wang, C. Hou, Z. Wang, C. Liang, C. Zhao, Y. Tong, X. Lu, S. Yang, *Adv. Mater.* **2017**, 1602868.
- 27 [24] H. Liang, A. N. Gandi, D. H. Anjum, X. Wang, U. Schwingenschlögl, H. N. Alshareef, *Nano Lett.* **2016**, *16*, 7718.
- 28 [25] C. Liu, C. Li, K. Ahmed, Z. Mutlu, C. S. Ozkan, M. Ozkan, *Scientific Reports* **2016**, *6*.
- 29 [26] J. Li, M. Yan, X. Zhou, Z. Q. Huang, Z. Xia, C. R. Chang, Y. Ma, Y. Qu, *Adv. Funct. Mater.* **2016**, *26*, 6785.
- 30 [27] M. Görlin, J. Ferreira de Araújo, H. Schmies, D. Bernsmeier, S. Dresp, M. Gliech, Z. Jusys, P. Chernev, R.
- 31 Kraehnert, H. Dau, P. Strasser, *J. Am. Chem. Soc.* **2017**, *139*, 2070.
- 32 [28] Y. Yu, W. Gao, Z. Shen, Q. Zheng, H. Wu, X. Wang, W. Song, K. Ding, *J. Mater. Chem. A* **2015**, *3*, 16633.
- 33 [29] M. Zeng, Y. Li, *J. Mater. Chem. A* **2015**, *3*, 14942.
- 34 [30] Y. Zheng, Y. Jiao, M. Jaroniec, S. Z. Qiao, *Angew. Chem. Int. Ed.* **2015**, *54*, 52.
- 35 [31] X. Wang, X. Gan, T. Hu, K. Fujisawa, Y. Lei, Z. Lin, B. Xu, Z. H. Huang, F. Kang, M. Terrones, R. Lv, *Adv Mater*
- 36 **2017**, *29*.
- 37 [32] D. Gao, J. Zhang, T. Wang, W. Xiao, K. Tao, D. Xue, J. Ding, *J. Mater. Chem. A* **2016**, *4*, 17363.
- 38 [33] M. D. Meganathan, S. Mao, T. Huang, G. Sun, *J. Mater. Chem. A* **2017**.
- 39 [34] Y. Surendranath, M. W. Kanan, D. G. Nocera, *J. Am. Chem. Soc.* **2010**, *132*, 16501.
- 40 [35] A. E. Mattsson, P. A. Schultz, M. P. Desjarlais, T. R. Mattsson, K. Leung, *Modell. Simul. Mater. Sci. Eng.* **2005**,
- 41 *13*, R1.
- 42 [36] X. Huang, M. Leng, W. Xiao, M. Li, J. Ding, T. L. Tan, W. S. V. Lee, J. Xue, *Adv. Funct. Mater.* **2017**, *27*.
- 43 [37] Z. W. Seh, J. Kibsgaard, C. F. Dickens, I. Chorkendorff, J. K. Norskov, T. F. Jaramillo, *Science* **2017**, *355*.
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